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(54) Title: PROCESS FOR THE TREATMENT OF WASTE METAL CHLORIDES

(57) Abstract: A process is described for treating the residues from metal chlorination processes wherein valuable volatile metal chlorides or metalorgano chlorides are recovered while low volatility metal chlorides and chloride complexes are reacted with a neutralizing humectant. The resulting neutral, dry solid is suitable for land fill disposal or for recovery of valuable metal constituents by extractive metallurgy techniques.

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WO 2004/096707 A1